



## AMENDMENT / RESPONSE TRANSMITTAL

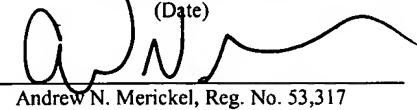
Applicant : Tois et al.  
 App. No. : 10/678,766  
 Filed : October 2, 2003  
 For : METHOD OF GROWING  
 OXIDE THIN FILMS  
 Examiner : Matthew J. Song  
 Art Unit : 1765

## CERTIFICATE OF MAILING

I hereby certify that this correspondence and all marked attachments are being deposited with the United States Postal Service as first-class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on

December 28, 2004

(Date)

  
 Andrew N. Merickel, Reg. No. 53,317

## Mail Stop Amendment

Commissioner for Patents  
 P.O. Box 1450  
 Alexandria, VA 22313-1450

Sir:

Transmitted herewith for filing in the above-identified application are the following enclosures:

- Response to Office Action in 3 pages.
- Copy of Declaration of Prior Inventorship w/attachments in 6 pages
- Return prepaid postcard.
- Please charge any additional fees, including any fees for additional extension of time, or credit overpayment to Deposit Account No. 11-1410.



Andrew N. Merickel  
 Registration No. 53,317  
 Attorney of Record  
 Customer No. 20,995  
 (415) 954-4114



## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant : Tois et al.  
 Appl. No. : 10/678,766  
 Filed : October 2, 2003  
 For : METHOD OF GROWING OXIDE  
 THIN FILMS  
 Examiner : Matthew J. Song  
 Group Art Unit : 1765

## CERTIFICATE OF MAILING

I hereby certify that this correspondence and all marked attachments are being deposited with the United States Postal Service as first-class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on

December 28, 2004

(Date)

  
 Andrew N. Merickel, Reg. No. 53,317
RESPONSE TO OFFICE ACTION

Commissioner for Patents  
 P.O. Box 1450  
 Alexandria, VA 22313-1450

Dear Sir:

The present paper is submitted in response to the Office Action mailed on September 28 2004 and is accompanied by a copy of a Declaration of Prior Inventorship Under 37 CFR §1.131 filed in the parent application. Applicants respectfully request consideration of the following Remarks.

Remarks begin on page 2 of this paper.